



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Masaru MITSUI

Application No.: 10/523,470

Docket No.: 122672

Filed: March 10, 2005

For: METHOD FOR MANUFACTURING MASK BLANK, METHOD FOR
MANUFACTURING TRANSFER MASK, SPUTTERING TARGET FOR
MANUFACTURING MASK BLANK

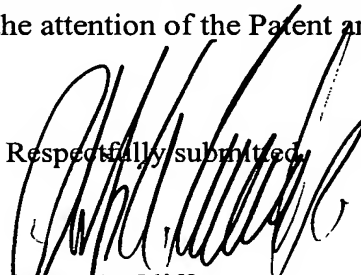
REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,


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JAO:PAC/crh

Date: August 31, 2005

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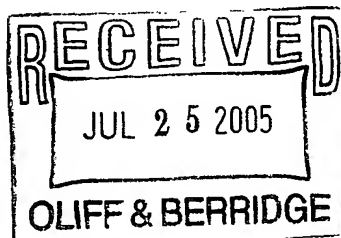


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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/523,470	03/10/2005	1756	1030	122672	3	11	3

25944
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CONFIRMATION NO. 3658

FILING RECEIPT



OC000000016544703

Date Mailed: 07/20/2005

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Applicant(s)

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Assignment For Published Patent Application

Hoya Corporation, Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/10438 08/19/2003

Foreign Applications

JAPAN 2002-238564 08/19/2002

Projected Publication Date: 10/27/2005

Non-Publication Request: No

Early Publication Request: No

Title

~~Mask blank manufacturing method, transfer mask manufacturing method, sputtering target for~~
METHOD FOR MANUFACTURING MASK BLANK, METHOD FOR MANUFACTURING
TRANSFER MASK, SPUTTERING TARGET FOR MANUFACTURING MASK BLANK

~~manufacturing mask blank~~**Preliminary Class**

430

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